

**Amendment to the Specification:**

Please replace the paragraph on page 3, lines 18-26, with the following amended paragraph:

The present invention provides a process for making high purity torsemide modification II comprising the steps of:

- (a) adding [torsemide modification I] a crude torsemide modification II to a solvent mixture comprising acetonitrile and water;
- (b) isolating torsemide modification I;
- (c) suspending the torsemide modification I of step (b) in water to form a solution;
- (d) adjusting the solution of step (c) to a pH of about  $10 \pm 0.2$ ;
- (e) filtering the solution of step (d);
- (f) adjusting the solution of step (e) to a pH of  $6.25 \pm 0.2$ ; and
- (g) isolating high purity torsemide modification II.